

Single event effect study on LGAD: Present status and prospects of femtosecond laser studies at ELI



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Sep 12 – 17, 2021 University of Birmingham

Outline

- ❑ Motivation
- ❑ Mortality Hypotheses
- ❑ Fs-Laser induced SEB (motivation/benefits/opportunities)
- ❑ Results from the Femtosecond Laser Studies of LGAD mortality at I
 Beamlines
 - ❑ Stability, Instability and irreversible breakdown (HV, Laser power
 threshold (TCT-SPA)
 - ❑ Probing the SEB Sensitive Depth of LGAD (TCT-TPA)
- ❑ Lessons learnt, steps forward/prospect/upgrades

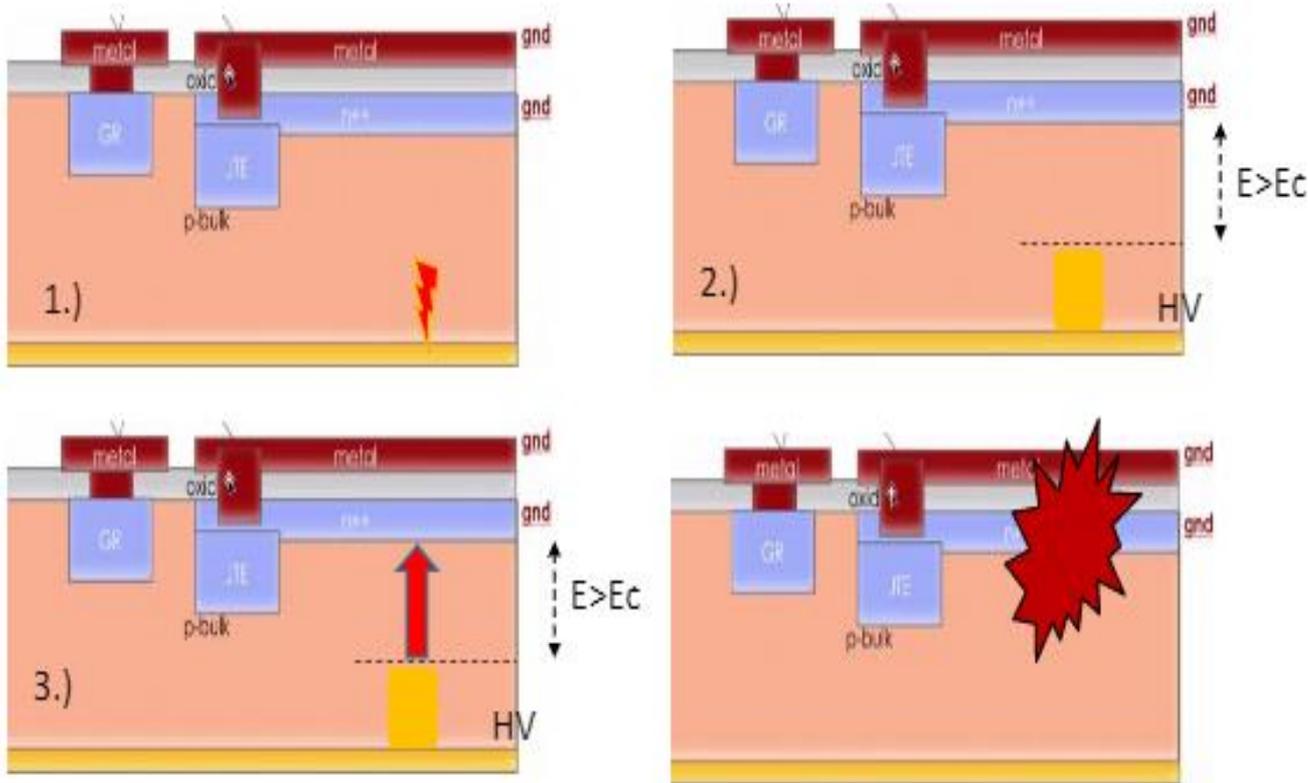
Quick introduction: LGADs breaking down at high V_{bias}

- ❑ Destructive breakdowns appear mostly in the test beams (TB) – not observed in the laboratory setups (Sr90, probe stations)
- ❑ Destructive breakdowns (fatalities) appear at bias voltages that are significantly (50 -100V) lower than those in the lab.
- ❑ They appear suddenly without a clear warning (increase of leakage current, instability in leakage current, changes in gain.
- ❑ There are indications that fatalities are beam related and not linked to the environmental conditions;
- ❑ The tested reasons/hypotheses for these breakdowns:
 - ❑ Is it the high electric field in highly irradiated sensors that is the problem?
 - ❑ Is it the gain of the devices that plays a role? Thickness?
 - ❑ Is it the irradiations that are the reason, or they merely facilitate the conditions where high bias voltages can be applied?
- ❑ The main difference between lab (Sr-90 with $E_{\text{max}}=2.3$ MeV) and TB (up to several tens MeV deposits – CMS paper) is the energy of the particles:

Can huge amount of charge in a single collision cause a conditions that lead to a destructive breakdown?

Ref/CMS paper: Mika Huhtinen, Highly ionising events in silicon detectors, CMS Note, March 2002

A possible explanation

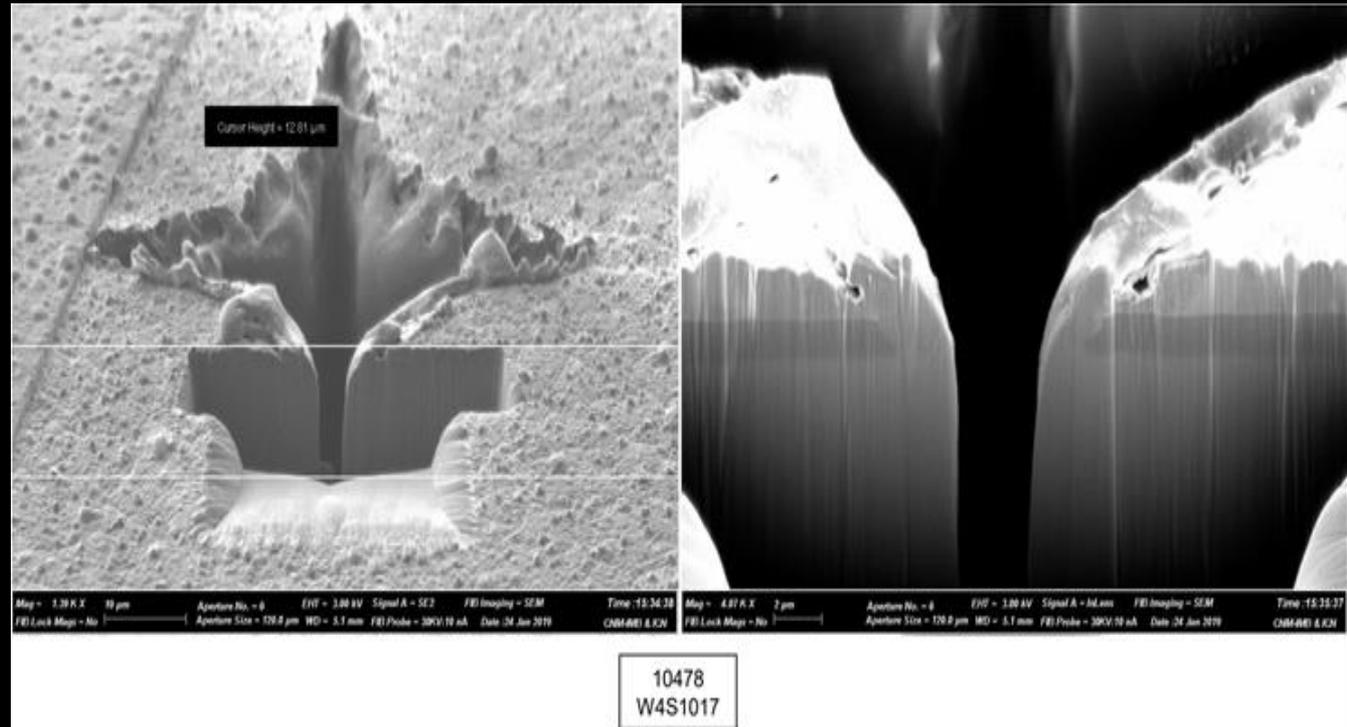


1.) larger deposition of the charge (fragments producing deposition in few μm as large as 1000 mips- (CMS tracker paper) in few μm (not possible with lab sources)

2.) larger density of carriers leading to collapse of the field (screening prevents the carriers from being swept away)

3.) once the field collapses the HV is brought closer to the pad which leads to very high field strength leading to avalanche breakdown and full discharge of sensors and bias capacitor

Fatality signature at the beam-tests: CNM LGAD burnout study (2019)

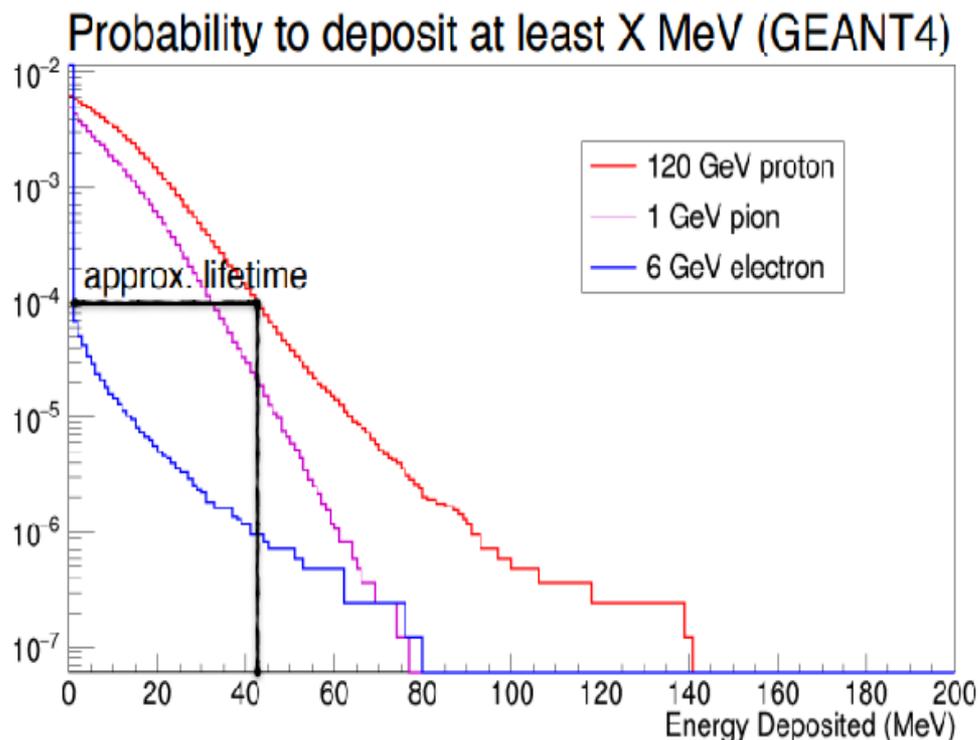


courtesy of CNM (ATLAS TB sensor)

https://agenda.infn.it/event/25712/contributions/129401/attachments/78738/101896/20210203_Lgad_Burn_Issues_v1.pdf

Proposed death mechanism

slide courtesy of Ryan Heller



- ❑ Rare, large ionization event
“Highly Ionizing Particle”
 - Excess charge leads to highly localized conductive path
 - Large current in narrow path → “Single Event Burnout”
- ❑ Estimate 40-50 MeV deposit needed
 - Rare, but possible in DESY 6 GeV electron beam (has been observed)
 - Common at LHC
- ❑ Some ability to model in TCAD, but not really “predictive” so far

Femtosecond laser induced **SEE/SEB event**

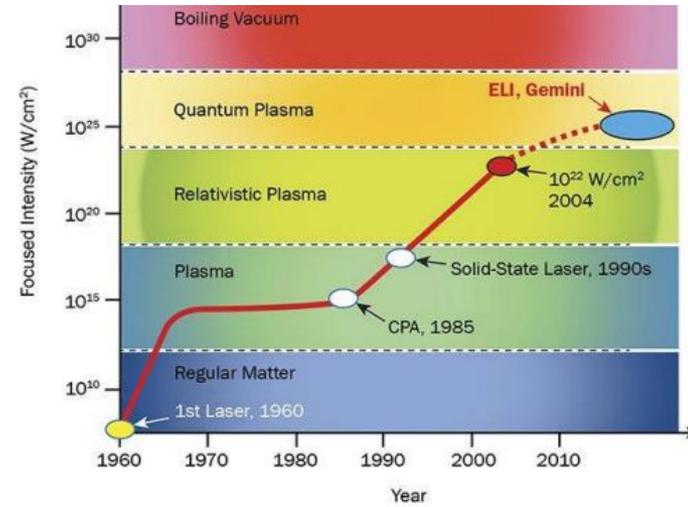
Hypotheses: If the speed of deposition is similar to MIP then the laser test with extremely short and high laser energy per pulse should lead to LGAD fatalities.

- Laser excitation of diodes is always a controlled way to excite those devices (biased as detectors).
- Electrical excitation is not appropriate because the non-intentional avalanches, in short, the **single event burnout phenomenology, has to be excited from the bulk if we want to research the mechanisms.**
- Field edge effects are always important but mainly because the internal electric field is always bigger around edges. Those field edge effects are contemplated during the device design phase or the device would never be biased.
- **SEB induced by fs-laser using front and backside illumination and probing the SEB sensitive depth in LGAD would bring a new insight, not possible by beam tests.**

Laser Facility: ELI Beamlines

Czech Republic
Dolní Břežany (on the outskirts of Prague)

www.eli-beams.eu



Experimental hall E1

Research program: Bio and Material Applications



Project supported by: Advanced research using high intensity laser produced photons and particles (ADONIS) Reg. n.: CZ.02.1.01/0.0/0.0/16_019/0000789

1. LGAD Mortality study with fs- TCT-SPA

Laser conditions:

$\lambda = 800 \text{ nm}$ (beam focused in the center of pad)

$d = 1.7 \mu\text{m}$

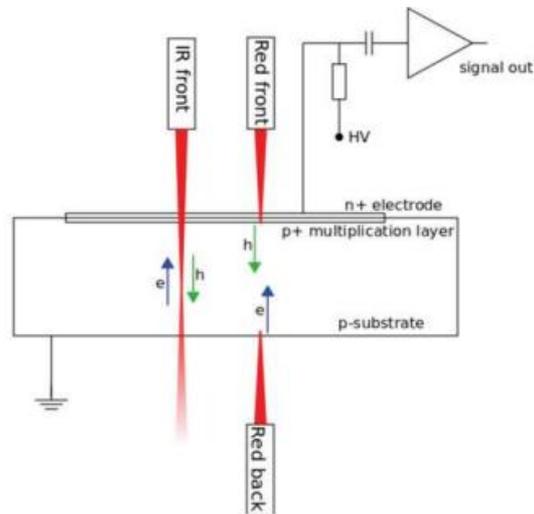
$w_0 = 0.85 \mu\text{m}$, $Z_R = 3.31 \mu\text{m}$

Cooling temperature: $-25 \text{ }^\circ\text{C}$

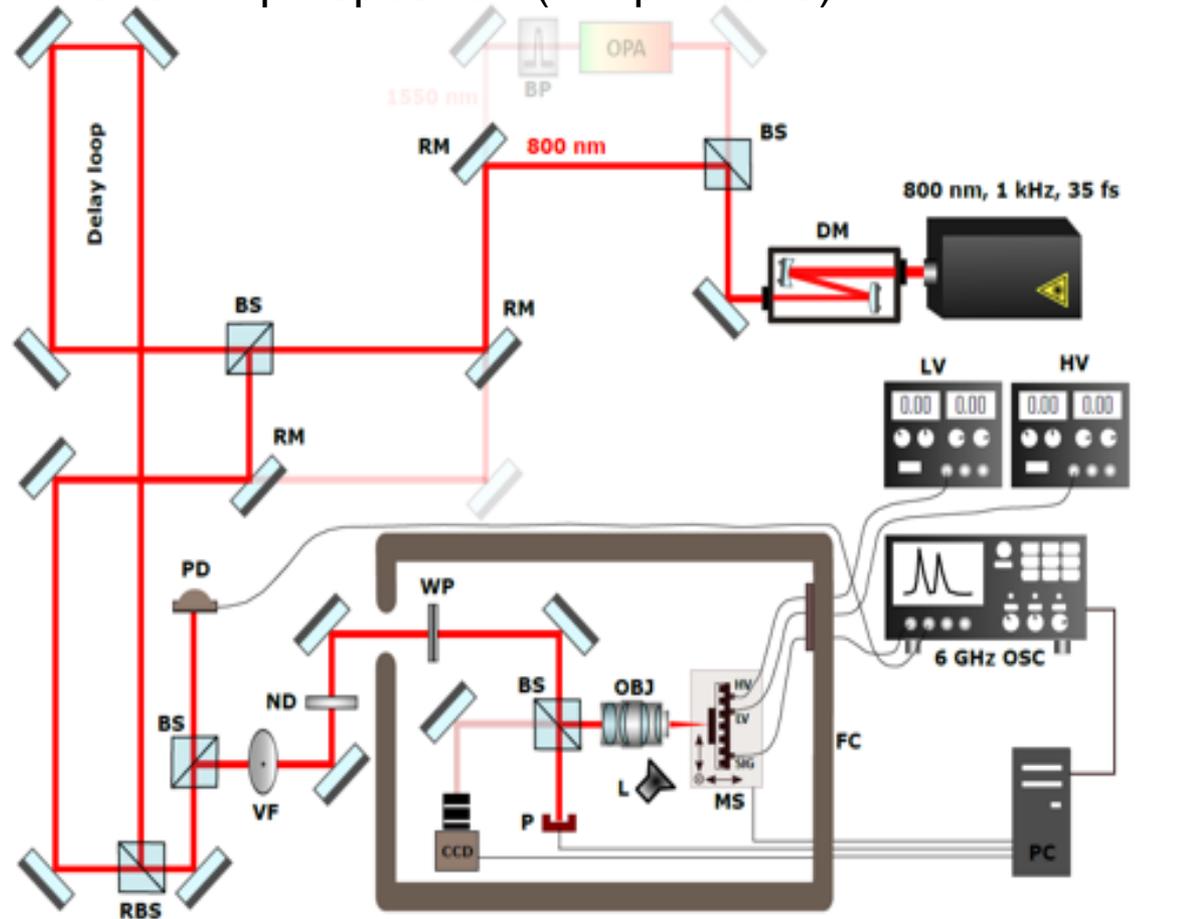
Laser power/energy range

1-50 nW (1-50 pJ)

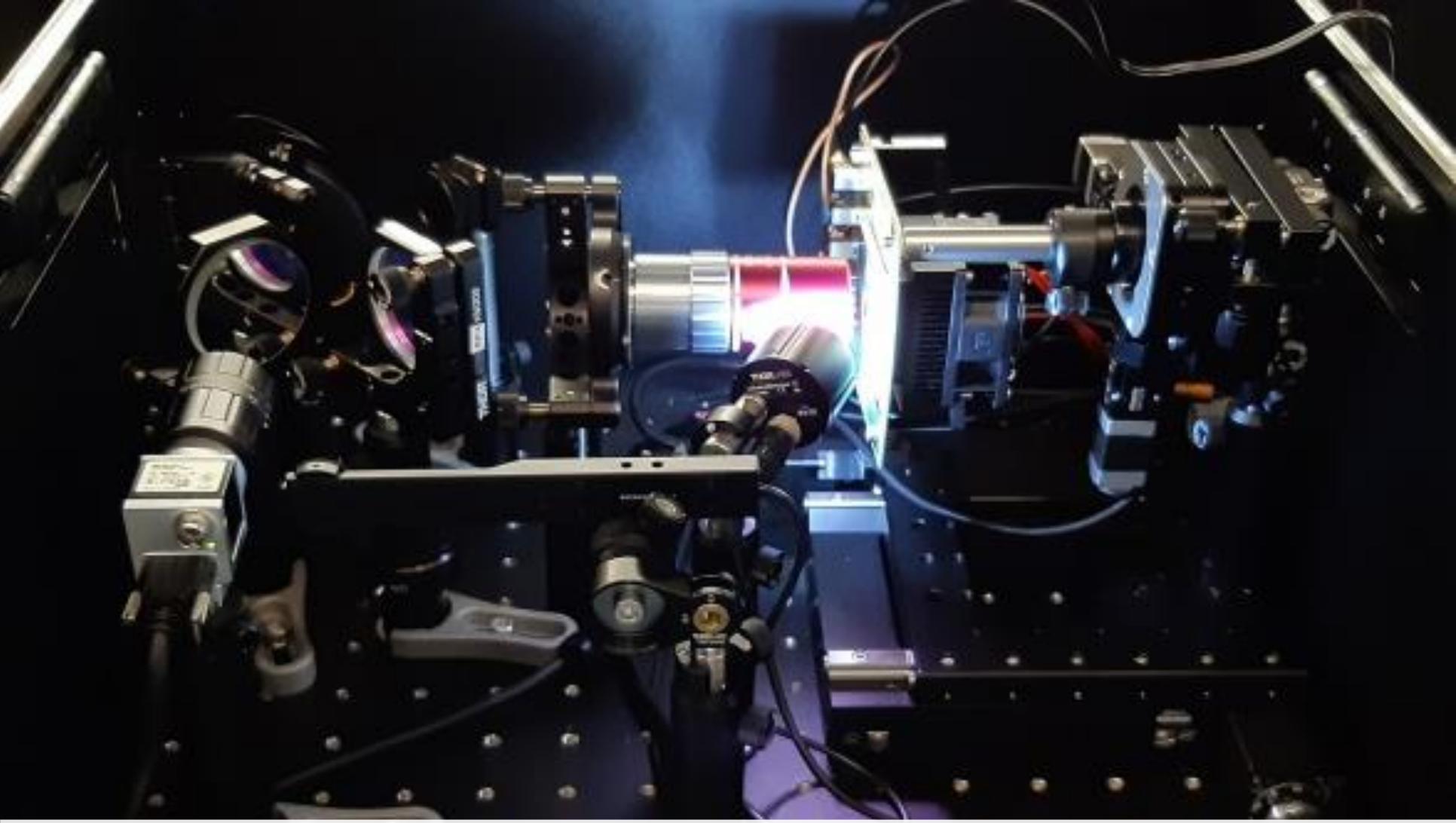
- Tests uses 800 nm (27 μm penetration) of 50 fs pulses with pulse of up to a 1 mJ. Pulses are focused to dimensions similar that of mip deposition (1-2 μm cone)



Schematic working principle of front/back TCT illumination of a silicon sensor and the charge carrier generation



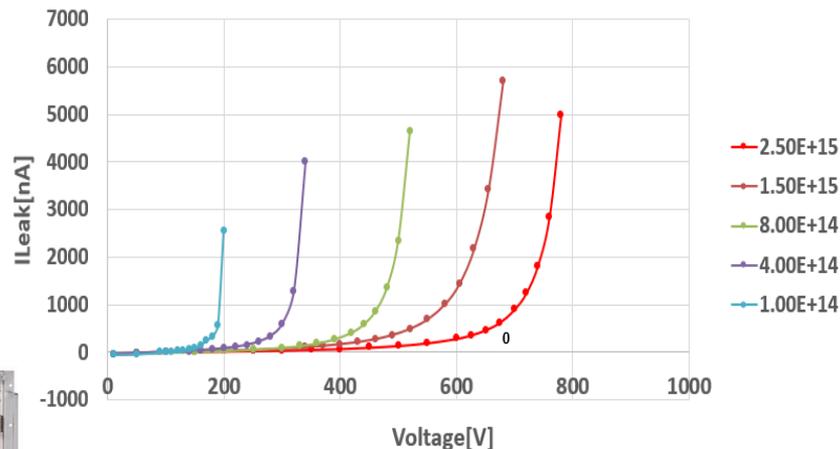
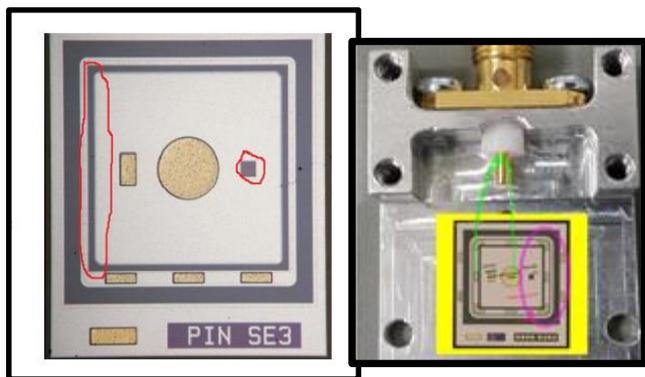
DM - demagnifier, BS - beamsplitter, OPA - optical parametric amplifier, BP - bandpass filter, RM - removable mirror, RBS - removable beamsplitter, PD - reference photodiode, VF - variable gradient ND filter, ND - fixed neutral density filter, WP - half waveplate, P - powermeter, OBJ - 100X objective, L - lens, MS - motorized XYZ stages, LV - low voltage power supply, HV - high voltage power supply, FC - Faraday cage



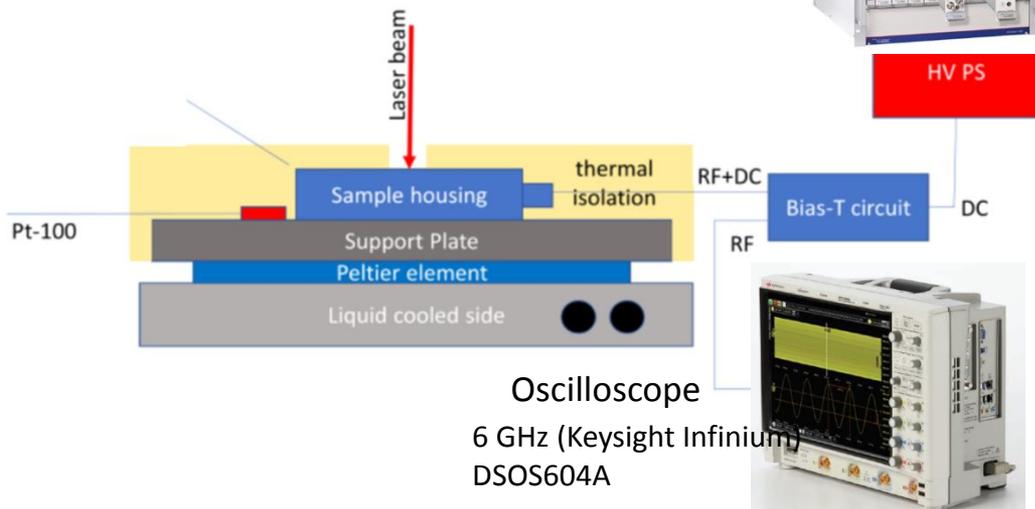
TCT set-up

Samples and readout

- ❑ The samples are from HPK-P2 run, the latest ATLAS/CMS LGAD fabrication (shown in many talk in the workshop)
 - ❑ W36 ($V_{gl} \sim 51.5$ V, $V_{bd} \sim 220$ V) (with Boron; no C enrichment)
 - ❑ I Exp: : $(0.4, 0.8, 1.5, 2.5)e15$ cm⁻²
 - ❑ II Exp:: fluences covered are the ones of interest for ATLAS & CMS: $1.5e15, 2.5e15$ cm⁻²



MORTALITY STUDIES



- Closed circuit chiller $T = -25$ C
- N₂ flushed to avoid condensation.
- No active amplifier used—we want large signals.
- Bias-T used to prevent discharge into oscilloscope
- No other bias filtering used
- ✓ HV power supply: EB1200305040000200 (Iseg)

Procedure Explained

1. feasibility study

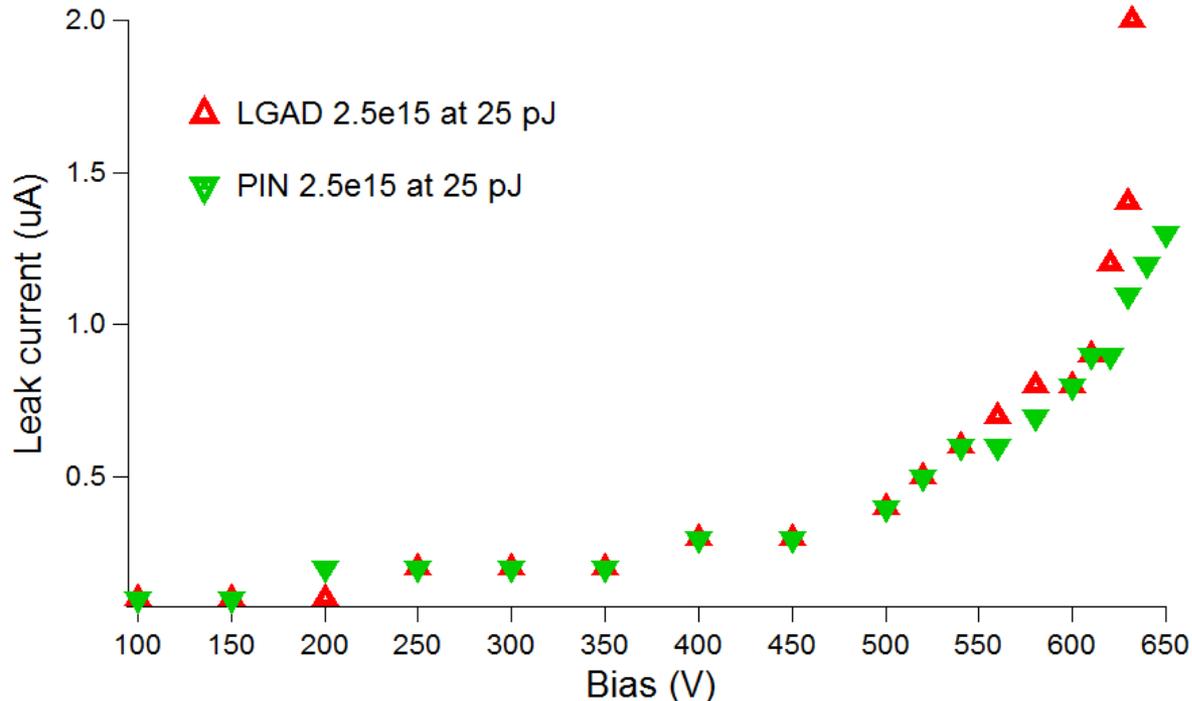
2. systematic study aiming to establish stable, instable and irreversible breakdown (HV, Laser power) threshold

- Starting with low pulse energy **1 pJ** the bias was increasing from **100 V to 650 V** (later this limit was extended to 670 V) whereas the signal was observed on the oscilloscope (waveforms were recorded) and the leak current was monitored.
- This procedure was repeated for increasing pulse energies with **5 pJ step until 50 pJ**; 5 pJ would correspond to 5 M e-h pairs
- For every scan we searched for the first symptoms of instability in the signal. When the signal started slightly “jumping”, we noted the values of energy and bias as "stability threshold“
- **After reaching the threshold the bias was further increased (to 670 V) to explore "unstable region"** as long as the signal can be safely measured by the scope.
- When the signal was high and significantly deformed the scope was disconnected and only leak current was observed with increasing bias.
- In the end the energy was set at 50 pJ and the bias was increased until the breakdown of the sensor

Measurements

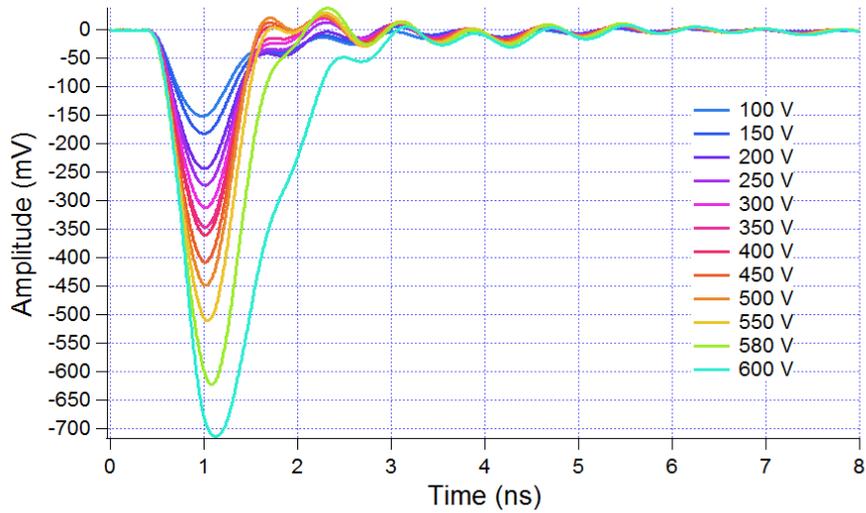
Leakage current

- The leakage current was recorded for different bias values.
- Nearly identical dependency was observed for all the samples at low illumination level. The small differences between LGADs and PINs appears only for higher laser power (see example below).
- Above stability threshold the current is jumpy and it's not possible to define the value.

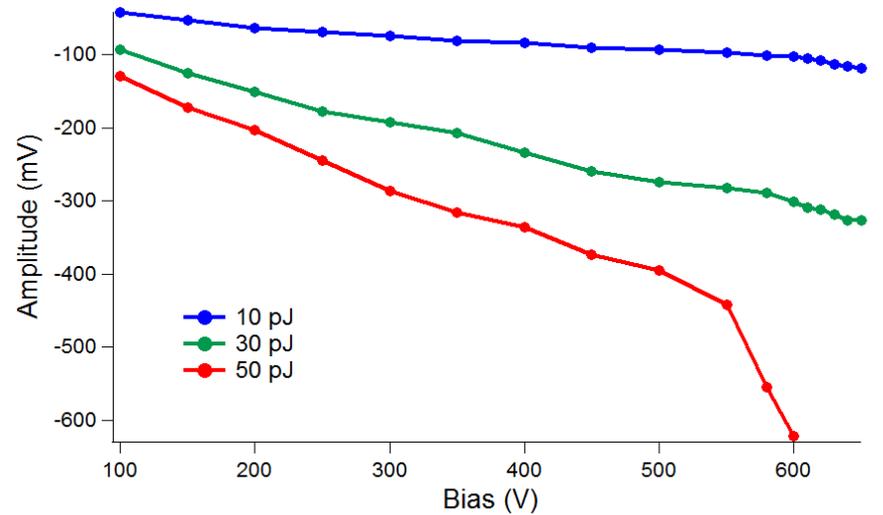
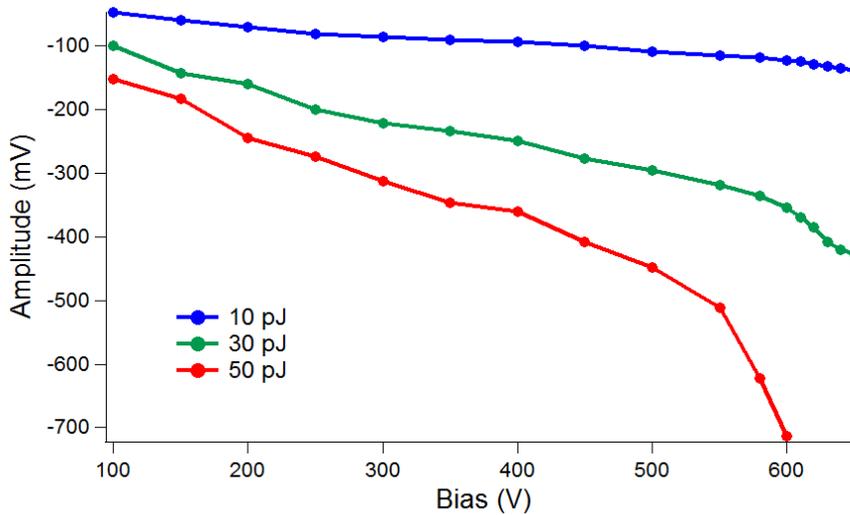
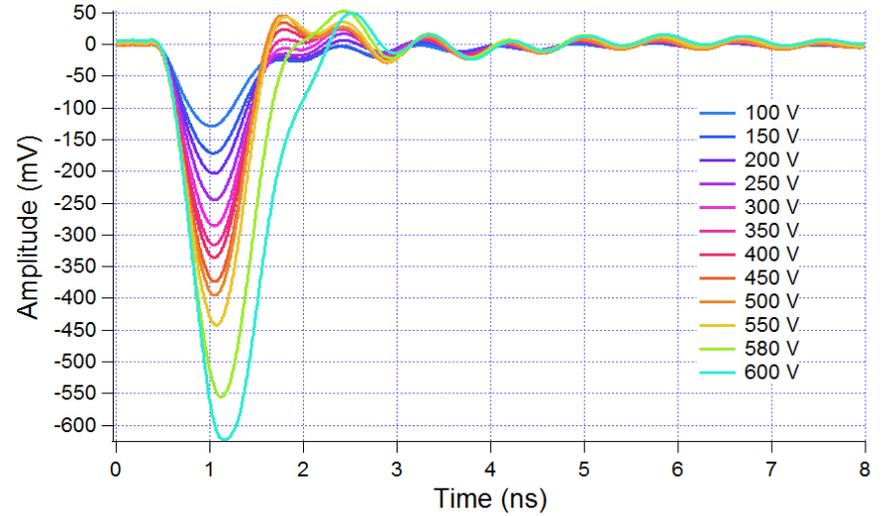


Waveform examples

LGAD 2.5e15 at 50 pJ



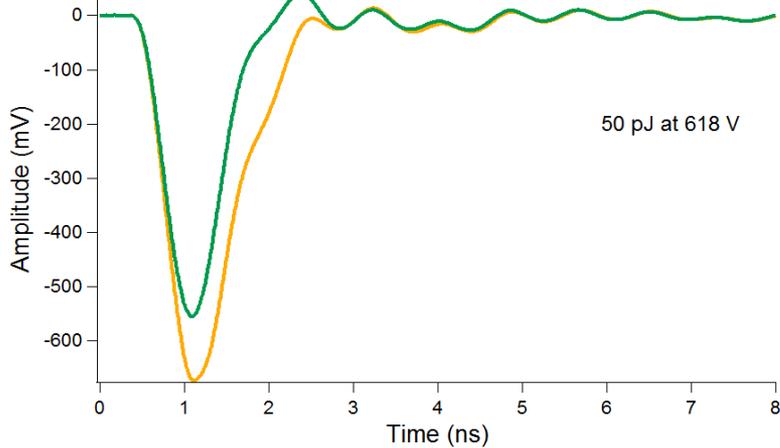
PIN 2.5e15 at 50 pJ



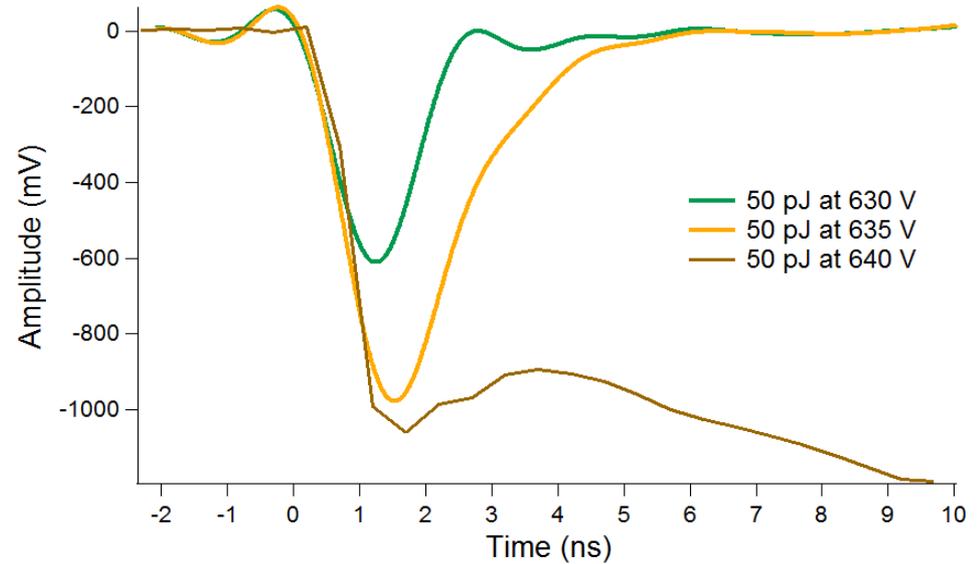
No significant different was observed between irradiated LGADs and PINs.

Stable/unstable and irreversible breakdown behaviour: Examples of waveforms

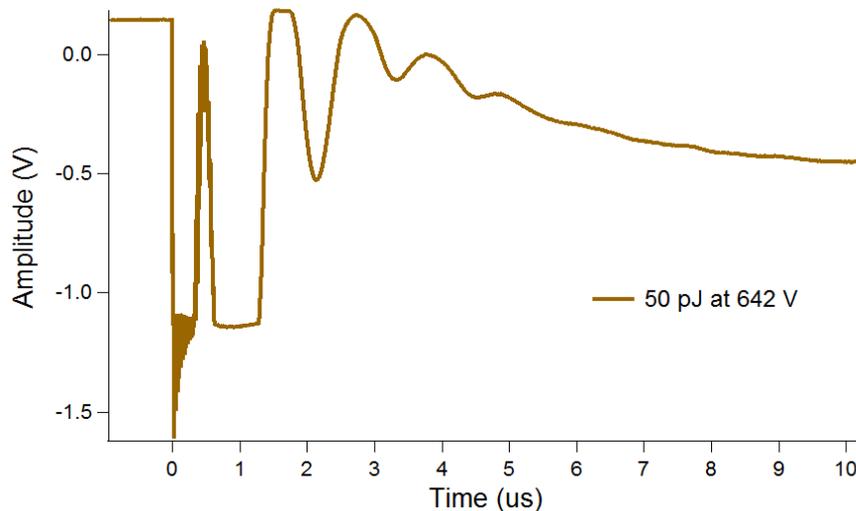
Stable condition



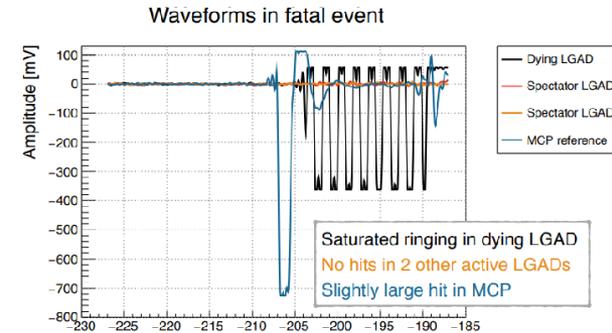
Unstable condition



Next to the irreversible breakdown

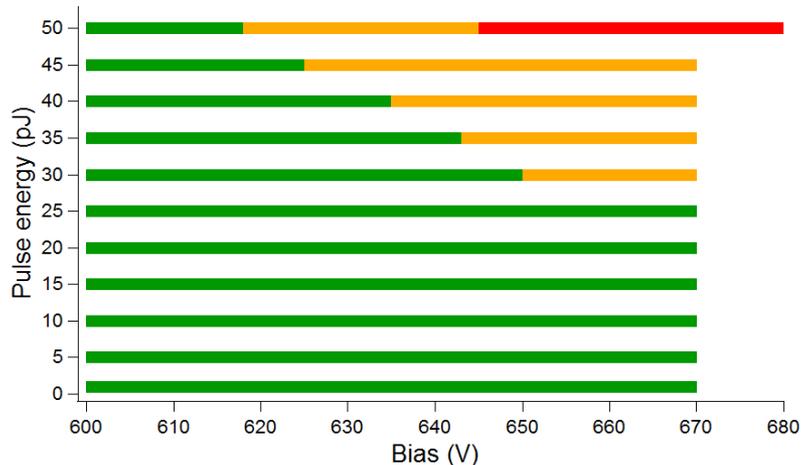


For comparison:
Fermilab/Example of death event

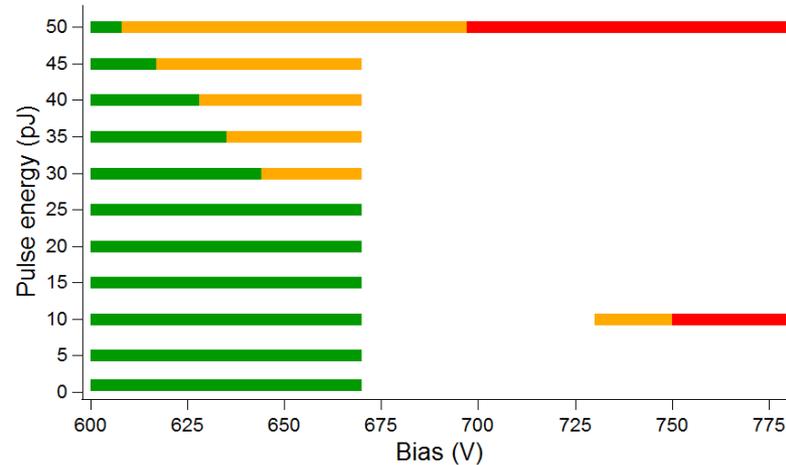


Stable/Instable/and damage damage thresholds

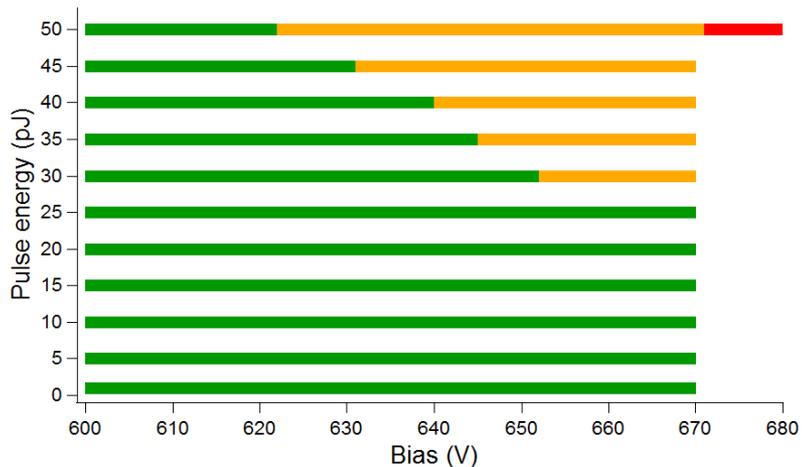
LGAD 1.5e15



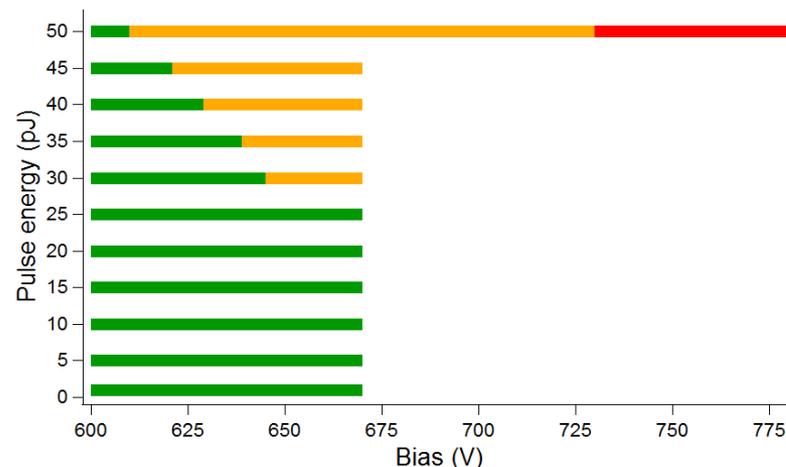
LGAD 2.5e15



PIN 1.5e15



PIN 2.5e15



No mitigation needed for 1.5e15 neq/cm2

- Stable region
- Unstable region
- Damage region

Risk mitigation for 2.5e15 neq/cm2

Implication for proton beams: one proton can cause such huge deposition that breakdown sensor irreversibly.

Summery: Stability and damage thresholds for 1.5e15 and 2.5e15 samples

E (pJ)	W36 LGAD 1.5e15		W36 LGAD 2.5e15		W36 PIN 1.5e15		W36 PIN 2.5e15	
	Stability threshold (V)	Damage threshold (V)						
1	> 670		> 670		> 670		> 670	
5	> 670		> 670		> 670		> 670	
10	> 670		> 670		> 670		> 670	
15	> 670		> 670		> 670		> 670	
20	> 670		> 670		> 670		> 670	
25	> 670		> 670		> 670		> 670	
30	650		644		652		645	
35	643		635		645		639	
40	635		628		640		629	
45	625		617		631		621	
50	618	645	608	697	622	671	610	730

Bottom line: No death observed in 50 micron sensors with bias < 645 V

2. Mortality study with fs-TCT-TPA

Accurate depth for triggering SEB - particularly the role of charge io determination of the SEB sensitive depth is important for guiding radiation hardness assurance methods. Many heavy-ion accelerator test facilities lack the high energy ions required for penetration deep into the substrate region.

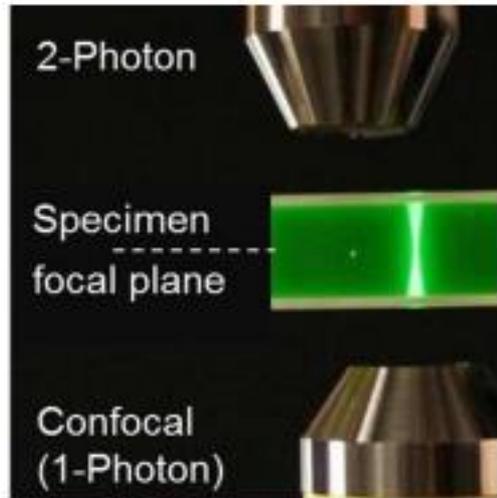
TCT-TPA seems to be promising tool for probing SEB depth in LGAD

Open question:

- Does the position of deposition inside LGAD matter? It can be that it is not the same if large amount of charge is released on top or on the bottom of the active layer (a clear case for TPA study, see the next talk)
- What is the “threshold for charge deposition” at given HV bias, at different LGAD depths that leads to destruction of the sensor?

Probing the SEB Sensitive Depth of LGAD: TCT-TPA

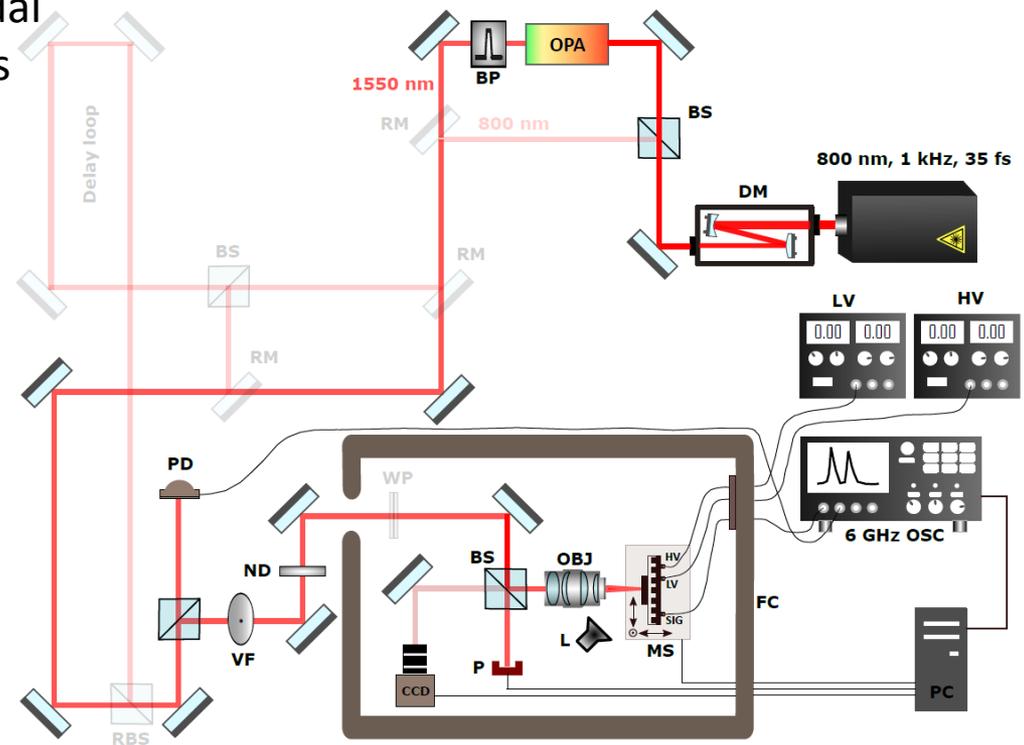
Challenges: The charge density is proportional to the square of the intensity of the laser beam, but because intensity is proportional to $1/r^2$ (where r is the radial distance from the long axis of the ellipsoidal focal area), the ionized charge density falls off as $1/r^4$.



Photography: Cicaron Yanez, University of Central Florida

Configuration of TCT-TPA

- *Final parameters*
- $w_0 = 1.52 \mu\text{m}$
- $Z_R = 7.74 \mu\text{m}$

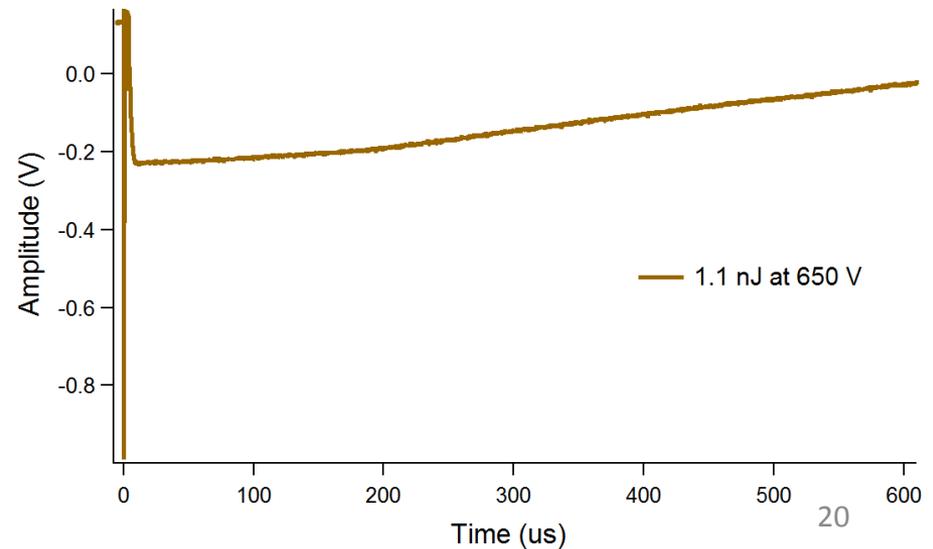
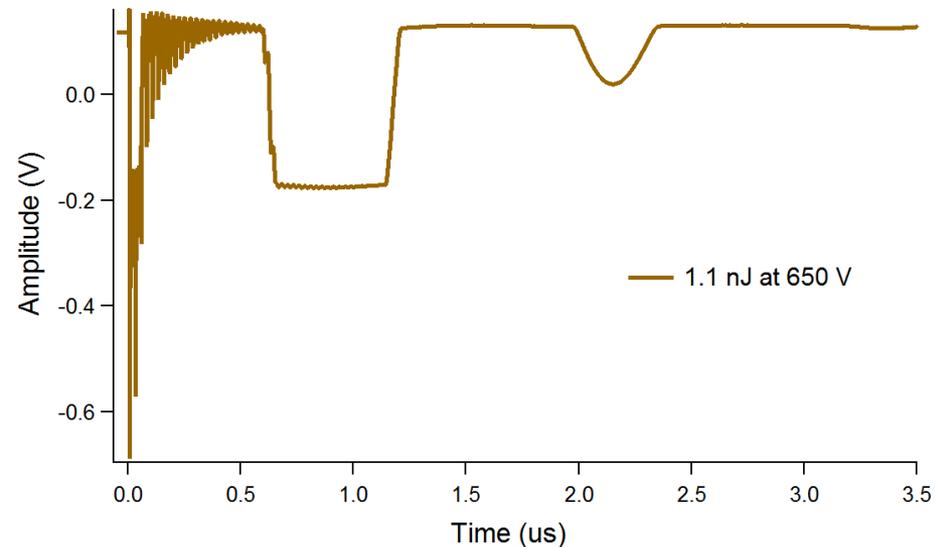
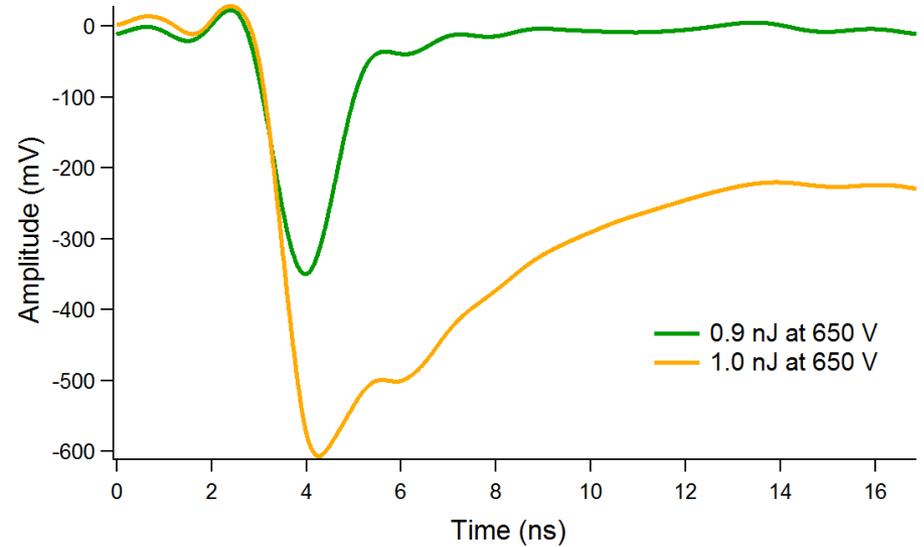


Unstable region

Unstable region corresponds to the power giving significant changes in the signal.

Example of waveforms for LGAD 1.5e15

Above certain threshold the signal is completely deformed and extended to microsecond range. Situation is very similar to SPA case.



Stability threshold vs Z

We managed to measure stability threshold for three different values of bias (650 V, 620 V, 600 V) in the most relevant Z range.

For every Z-position in relevant range the threshold was found. Idea was to see if mortality/stability limits of the device depends on the depth (position where the charge is generated).

We can see that in the range considered as “inside device” corresponding to 20-32 μm . the stability is more or less constant

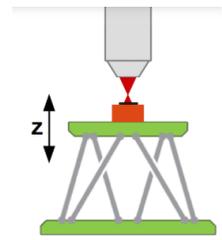
Conclusion: It seems that stability (maybe also mortality) does not change if we generate the charge closer to the front or closer to the back of the device.

SPA:

Light absorption anywhere along beam

TPA:

No signal, if focal point not inside detector

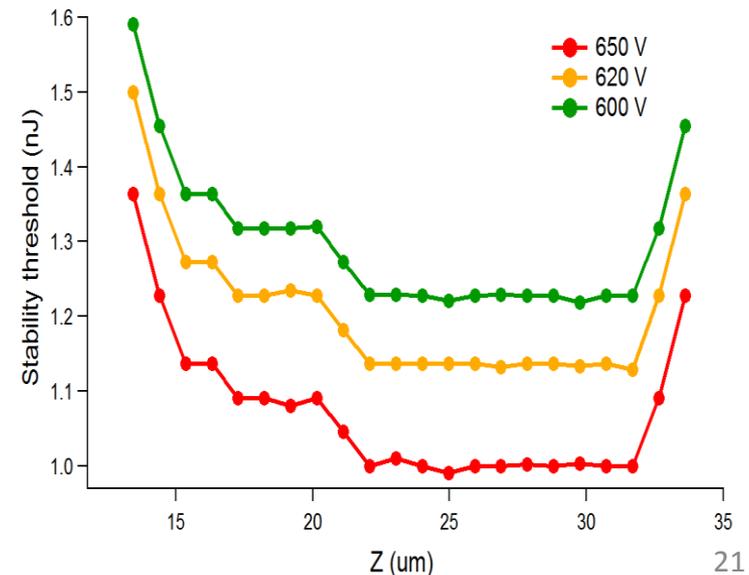


Irradiation:

defects in band gap

→ single photon absorption possible

→ TPA measurements need to be corrected



SENSOR DAMAGE INSPECTION UNDER ELECTRONIC MICROSCOPE

SPA

The added piece to the puzzle

- The “avalanche” seems to be triggered in the centre of opening where the laser hits the sensor, but the damage occurs at the point metal-Si interface, as there is a resistive path at metal-si interface which causes the heating and melting away the silicon. At lower bias voltages these sensors can take huge abuse with highly energetic laser pulses and that doesn't hurt them. So it must be field related.



W36 LGAD $1.5e15 \text{ cm}^{-2}$ (I ex

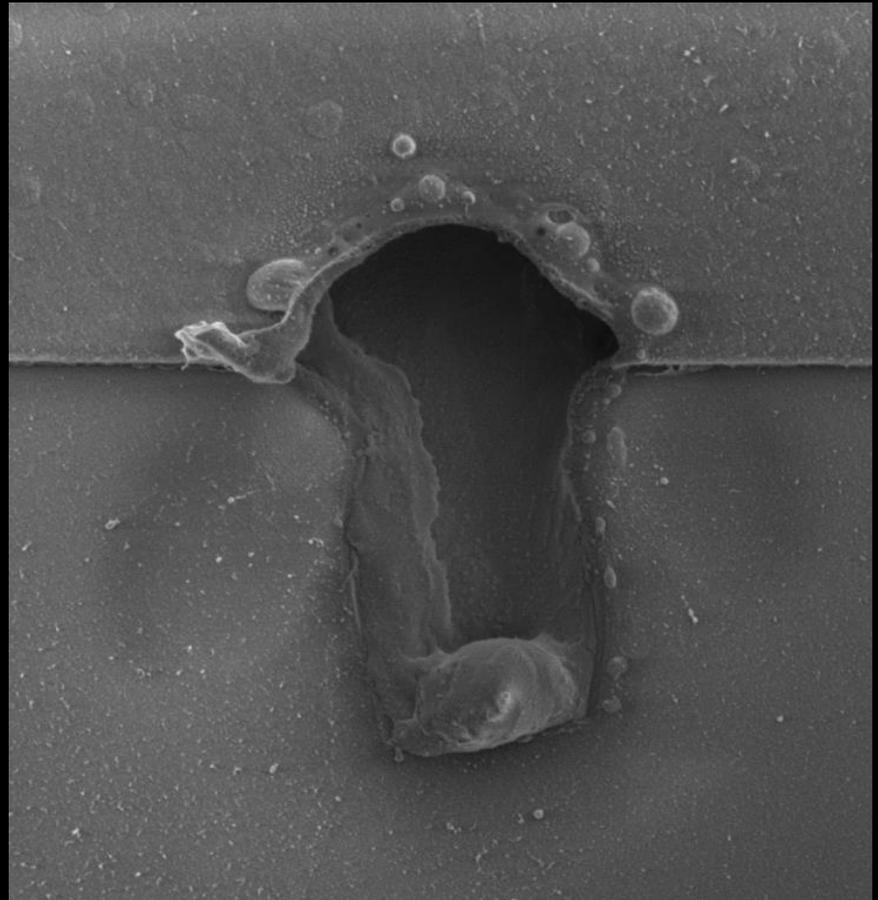
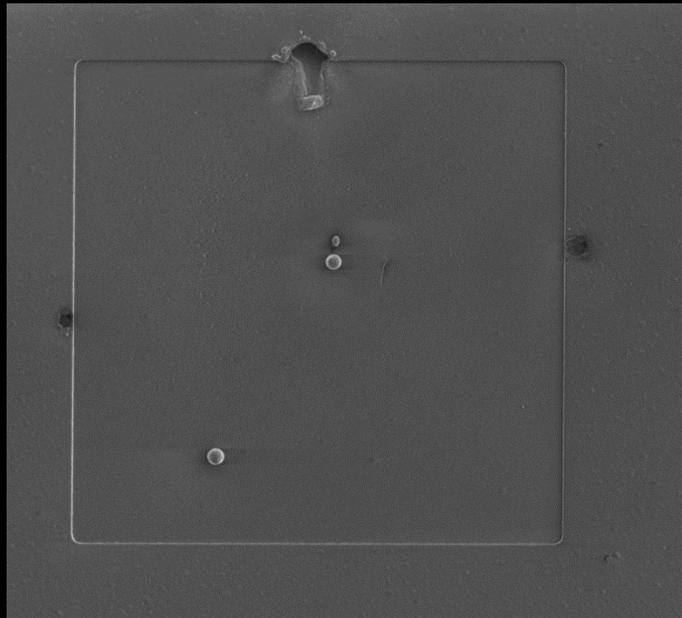
- ✓ The HV was set to 680 V
- ✓ After 3 nW illumination at 680 V the sample broke down (~10 MeV of deposited energy).

- No crater fatality signature seen as it was the case in test-beams; this is the most probable because in ELI tests we did not use 10 nF capacitor (set on timing board) so damage happened later. There is no discharge through sensor, and thus no crater rupture.

SPA

Damaged by SPA: 50 pJ, 692 V

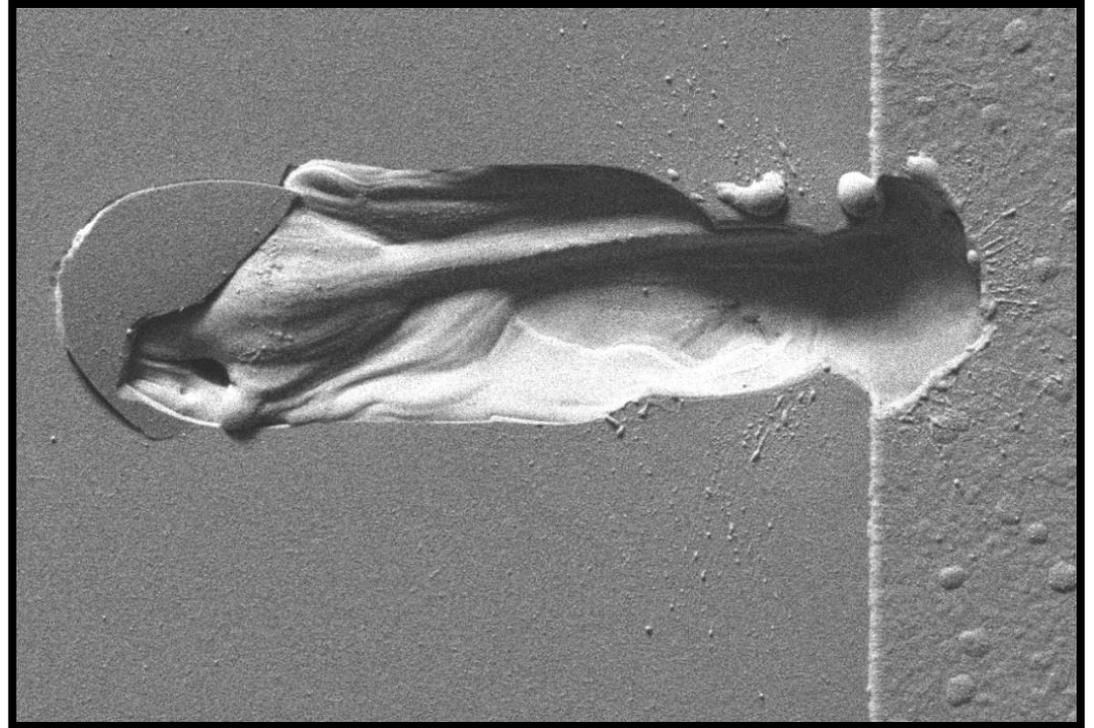
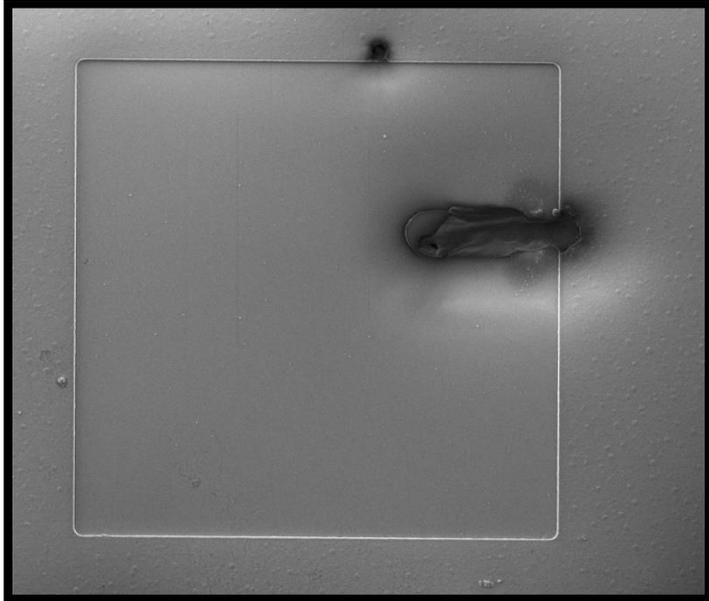
LGAD 2.5e15



SPA

LGAD 1.5e15

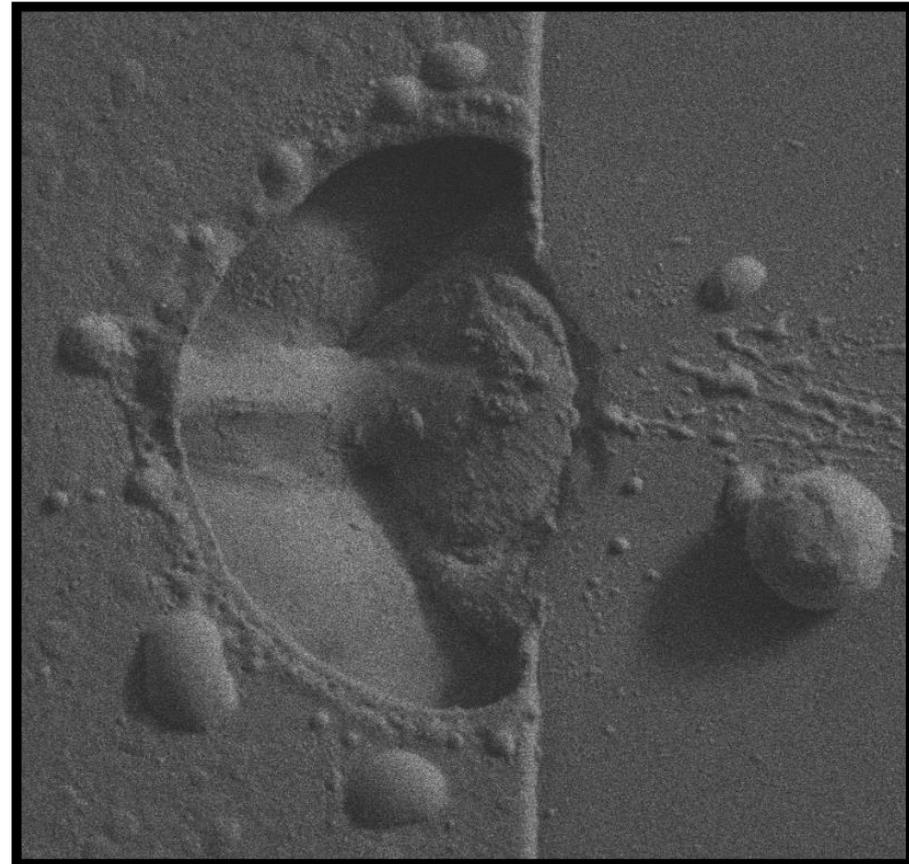
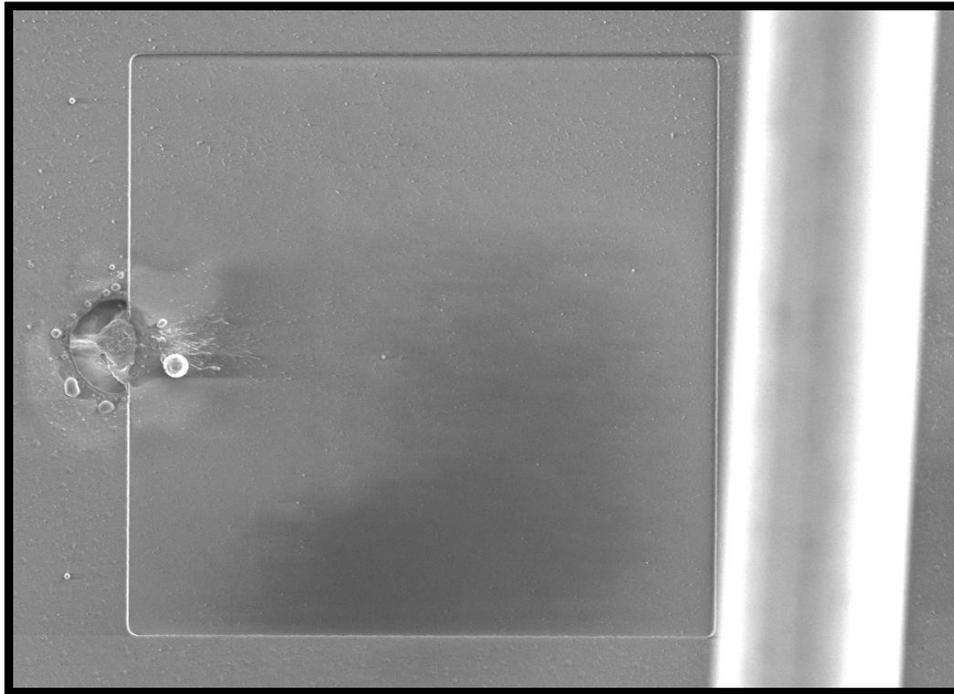
Damaged by SPA: 50 pJ, 625 V



SPA

PIN 2.5e15

Damaged by SPA: 50 pJ, 730 V



Edge effect: metal-semiconductor

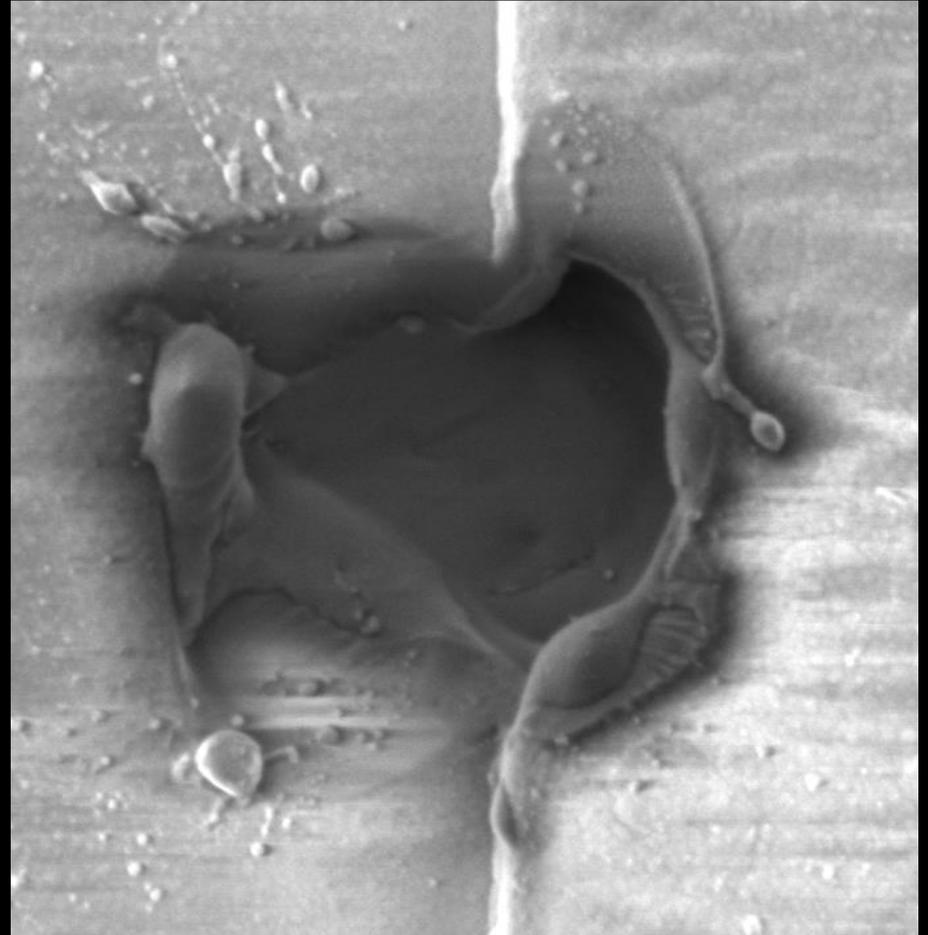
The energy for the crater (seen in proton-beam tests) comes from the filtering capacitors.

SPA

PIN 1.5e15



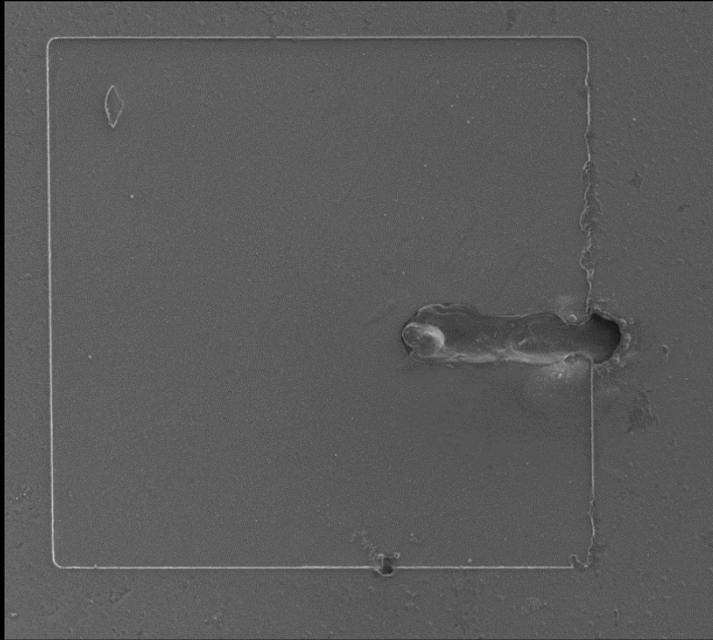
Damaged by SPA: 50 pJ, 671 V



TPA

LGAD $1.5 \times 10^{15} \text{ n}_{\text{eq}}/\text{cm}^2$

completely damaged by TPA at 3.2 nJ and 600 V



Location and character of damage areas look quite similar to those obtained by SPA breakdowns

Summery: Steps we made

- A feasibility study conducted at the laser facility ELI Beamlines confirms that highly energetic fs-laser pulses can produce Single Event Effect and Single Event Burnout (SEB) conditions in irradiated Low Gain Avalanche Detectors (LGADs) and corresponding PIN diodes
- ✓ Comprehensive and systematic mortality study on LGADs and PINs has been conducted to experimentally set stability, instability, and irreversible damage thresholds (HV bias, laser power) for LGADs and PINs exploiting fs-laser
- ✓ Destructive and non-destructive measurements using fs-laser have been used to investigate the burnout process. Non-destructive measurements are only able to indicate the onset of avalanche multiplication. On the other hand, destructive measurements are able to provide more detail about the burnout process.
- ✓ Using TCT-Two Photon Absorption (TPA) to study the mechanism that triggers SEU/SEB condition in LGADs as function of illumination position establishes this technique as a promising tool for the more advanced exploration of SEE not only in LGADs but also in other Si-based sensors.
- ✓ To achieve these results, a highly flexible, and versatile fs-laser-based TCT experimental setup has been developed at ELI Beamlines, allowing two TCT modalities at the same setup: SPA at 800 nm and TPA at 1550 nm laser wavelength

Advantages: fs- laser tests vs beam tests

Presented work demonstrates that Single Event Burnout event can be systematically studied using fs-laser in a such controlled way that LGAD once brought to the instable condition that is next to the irreversible breakdown but not yet broken, could be returned to the stable operable condition by decreasing HV by a few volts;

This excellent control over the very unstable but not yet irreversible breakdown conditions of LGADs is unique for the presented fs-laser beam tests since such control is not possible to be achieved in proton beams-tests.

As the primary outcome, the presented study sets the reference values for stability, instability, and damaged thresholds mapping this way the safety region and defining the turning point after which irreversible breakdown is unavoidable.

Lessons learnt

ELI Mortality campaigns significantly improved understanding of LGAD's death mechanism

- - it is almost certain that this is not LGAD feature. It is property of silicon at high fields.
 - Irreversible breakdowns are unrelated to gain; LGADs and PINs suffer the same.
 - Irreversible breakdowns are also radiation damage unrelated and not fluency dependent; there is HV and laser power dependence.
 - link to the fluences is only because irradiations enables sensors to be biased at higher HV; (HV >580 V); this leads to the higher el field that LGAD can not sustain.
 - the reason for fatalities is the high field (voltage)
 - Crater signature not observed in ELI mortality study since capacitor was not mounted to sensors' household (housings provided by IJS).
 - Damage appearance preference: at pad edge

We manage successfully to define the stability and damage thresholds for 1.5×10^{15} and $2.5 \times 10^{15} n_{eq}/cm^2$ HPK (WF36) samples;

- destructive breakdown observed at bias voltages around 650 V at laser energies of 50 pJ; this is in agreement with SEB
- Bottom line: 50-micron HPK-WF35 sensors seem quite safe with HV bias < 645 V.
- there is no difference between PIN and LGAD and 1.5×10^{15} and 2.5×10^{15} .
- there are three regions stable – instable – destroyed

Open questions and steps forward

Correlation of the mortality rate with the electric field and deposited energy.

Safe voltage for a given thickness

- Thick sensor vs. thin sensor; maybe thin sensor are more resistant to SEB

Understanding the process

- Is the damage mechanism the same for particles and light (same photos as at observed at ELI observed also at UCSC); HV threshold for irreversible breakdown is lower in beam tests than in laser tests at ELI; Should we compare the total ionization in MeV, or instead the rate of ionization in MeV / fs ?
- The question is it really impossible to break a sensor at 550V, or does the ionization threshold just raise to a huge value like 500 or 1000 MeV? This is hard to answer at the test beam but maybe can be addressed with a scan of the laser power at lower bias (some hint on the next page)..

Mitigation techniques

- Carbon enrichment seems most advanced solution so far
- Is there a room for improvement in the design
 - An active quenching strategy is way more evolved, it needs a deep understanding of power microelectronics because the power bursts are too fast (that is the main reason of the fast discharge of any HV capacitor around the detector diode).
 - Engineering: Low resistivity bulk might act as quenching resistor

Open question raised: Is it really impossible to break a sensor at 550V, or does the ionization threshold just raise to a huge value like 500 or 1000 MeV?

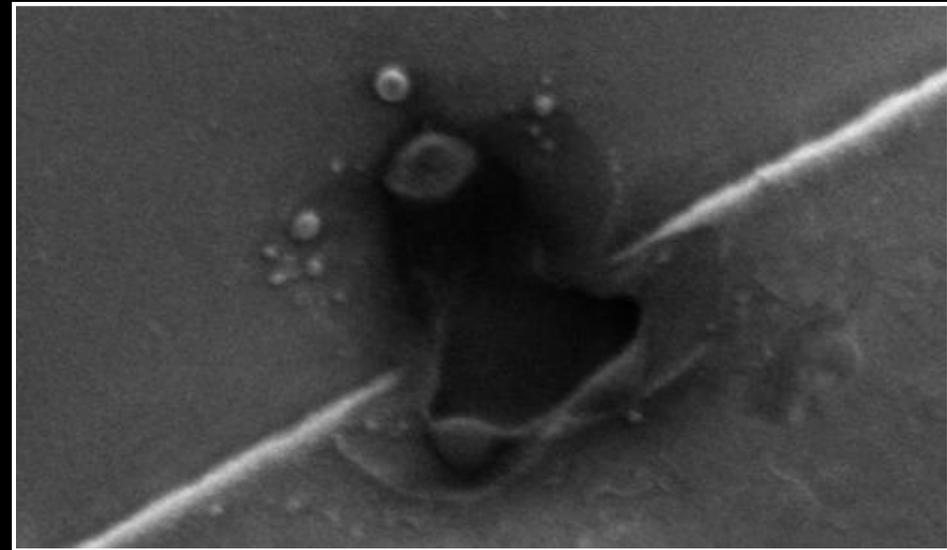
TREDI2021 Workshop; G.Medin et al

- ✓ The HV was increased in steps, and survival of sensor at each step (chosen HV) was tested by increase of laser power till sensor brake down.

LGAD WF36

$2.5e15 \text{ n}_{eq} \text{ cm}^{-2}$

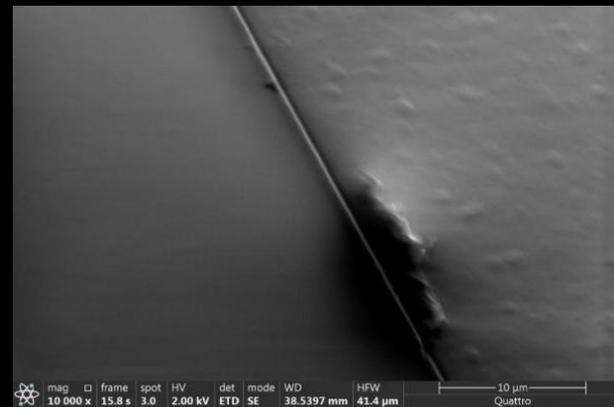
HV = 450 V, $P_{laser} = 6 \mu\text{W}$



PIN

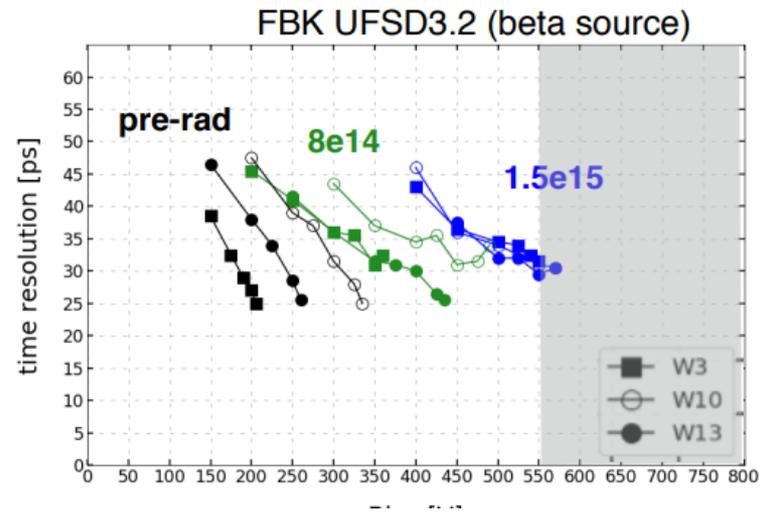
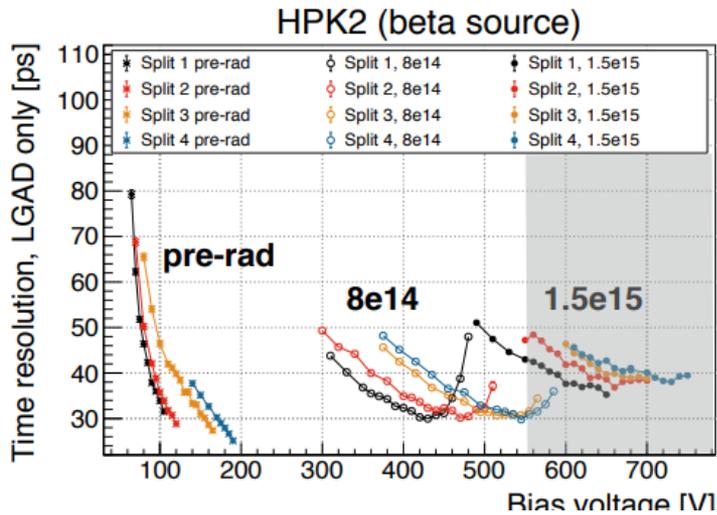
$1.5e15 \text{ n}_{eq} \text{ cm}^{-2}$

HV = 400 V, $P_{laser} = 6 \mu\text{W}$



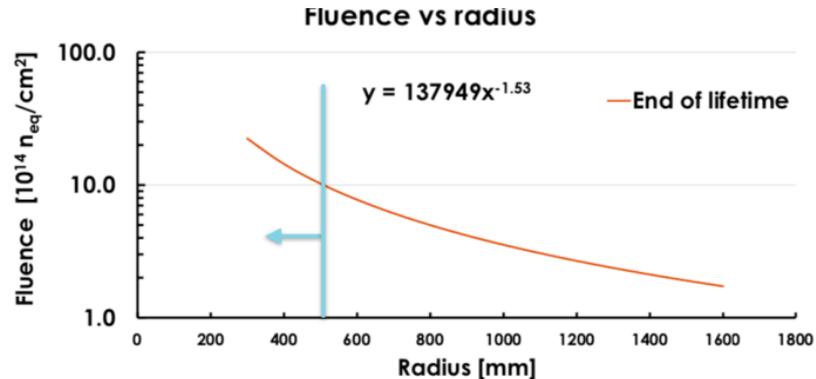
Context for ETL

- ✓ **Some FBK wafers deliver required performance < 550V at all ETL fluences.**
- Next tests at ELI



Only HPK sensors at innermost radii require reduced voltage.
 Few percent of ETL area.

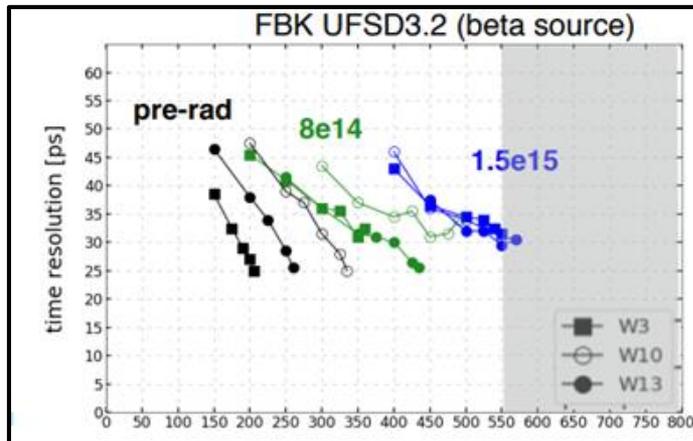
(courtesy of Ryan Heller)



Future steps at ELI

✓ To exploit UFSD3.2 sample

- First production of UFSD 45 um, Investigate the Carbon dose range 0.1 – 1.2
- Deep implant:
- Investigate the feasibility of deep implant B+C, Investigate



Wafer #	thickness	GL DEPTH	Dose Pgain	Carbon	Diffusion
1	45	Standard	L	1*A	L
2	44	Standard	L	1*A - Spray	L
3	45	Standard	L	0.8*A	L
4	45	Standard	L	0.6*A	L
5	45	Standard	L	0.4*A	L
6	25	Standard	VVL	A	L
7	45	2 um	L'	1*A	L
8	55	2 um	L'	1*A	L
9	45	2 um	L'	0.6*A	L
10	45	2 um	M'		L
11	45	2 um	M'	1*A	L
12	45	2 um	M'	0.6*A	L
13	45	2 um	M'	1*A	H
14	55	2 um	M'	1*A	H
15	45	2 um	M'	0.6*A	H
16	45	2 um	H'		H
17	45	2 um	H'	0.8*A	H
18	45	2 um	H'	0.6*A	H

<https://www.sciencedirect.com/science/article/pii/S0168900218317741>

✓ To exploit LGAD's irreversible breakdown vs. thickness

✓ Performing laser illumination (SPA & TPA) from the LGAD's back side

Thank you

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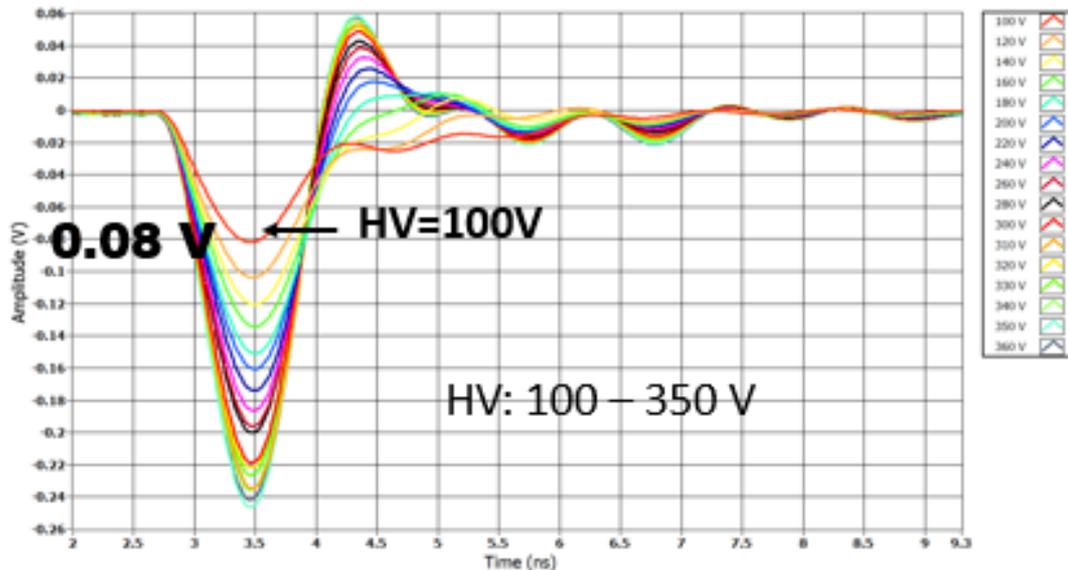
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We acknowledge ELI Beamlines in Dolní Břežany, Czech Republic, for providing beamtime and thank the instrument group and facility staff for their assistance. LM2018141, MEYS – Large research infrastructure project ELI Beamlines. This work was supported by the projects Advanced research using high-intensity laser-produced photons and particles (ADONIS) (CZ.02.1.01/0.0/0.0/16_019/0000789), Structural dynamics of biomolecular systems (ELIBIO) (CZ.02.1.01/0.0/0.0/15_003/ 0000447) (both from the European Regional Development Fund and the Ministry of Education, Youth and Sport)

BACKUP SLIDES

Correlation between pulse energy and energy deposit

LGAD WF36, $4e14 n_{eq}/cm^2$
 $P_{laser}=10 \text{ nW}$ (10pJ)



Generated Ne-h

1. Calculation from signal recorded on the diode at 10 nW

$$N_{e-h} = \frac{1}{e_0 R} \int_0^{5 \text{ ns}} V_{sig}(t) dt$$

$$N_{e-h} \sim \frac{1}{1.6e-19 \text{ As } 50\Omega} 0.08 \text{ V} \cdot 1 \text{ ns} \sim 10^7 e-h$$

2. Calculation from the beam parameters at 10 nW

$$E_{pulse} = \frac{P}{\nu}$$

$$N_{e-h} = \frac{E_{pulse}}{e_0} \cdot Q_E \cdot R_{e-h}$$

$$N_{e-h} = \frac{10 \text{ nW}}{1000 \text{ s}} \cdot 0.5 \cdot 1 \cdot \frac{R_{e-h}}{1.6e-19 \text{ As}} = R_{e-h} \cdot 6.2 \cdot 10^7 e-h$$

3. A factor of 6 difference implies to large recombination possible. Recombination rate R is very much affected by the irradiation on. In order of both calculations to agree R has to be 1/6

4. The equivalent lost charge in the silicon to produce the same signal:

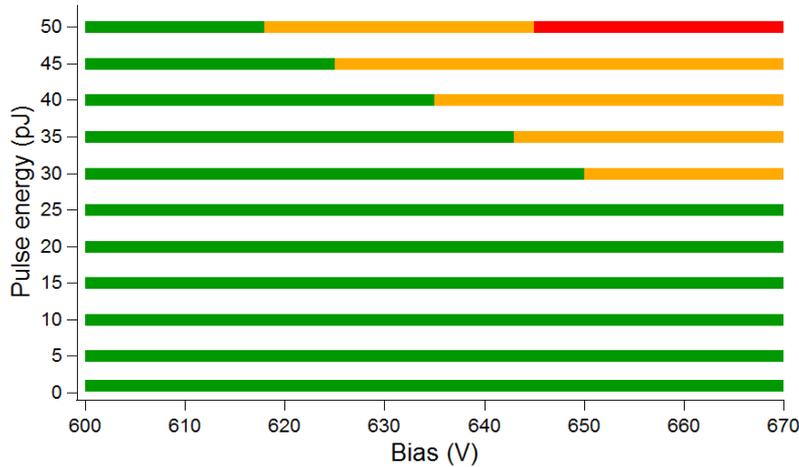
This is of the same order as seen in CMS paper

$$\Delta E = N_{e-h} 3.62 \text{ eV} = \sim 30 \text{ MeV}$$

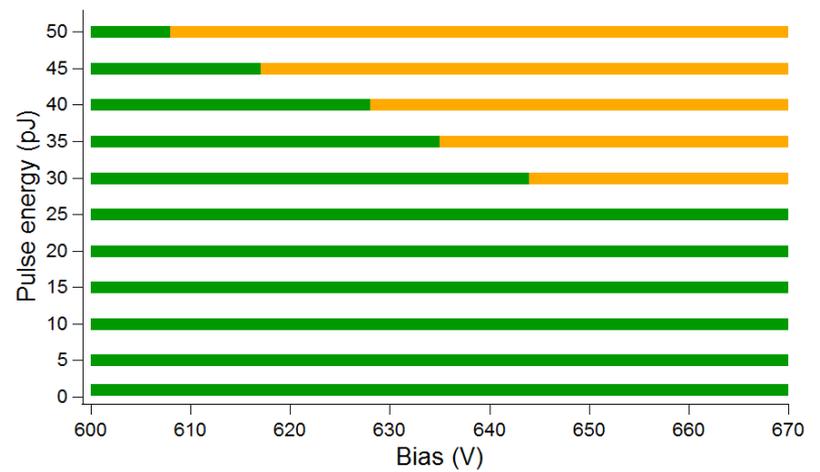
Pulse energy vs. Bias mapping

✓ **"safe operation" region below 50 pJ and 645 V**

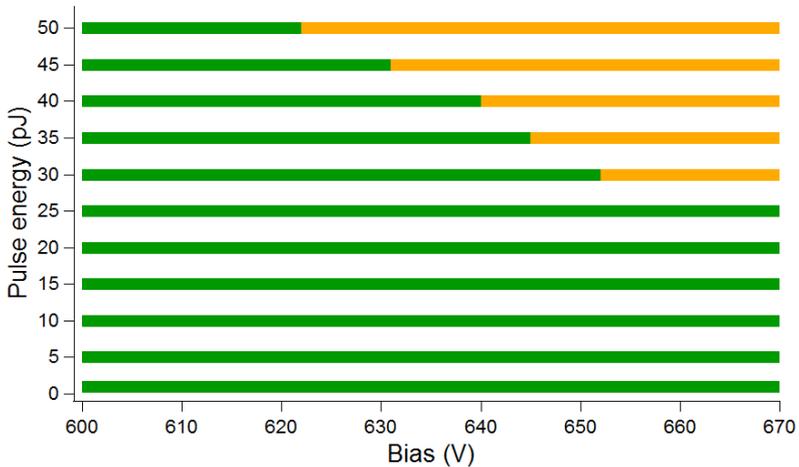
LGAD 1.5e15



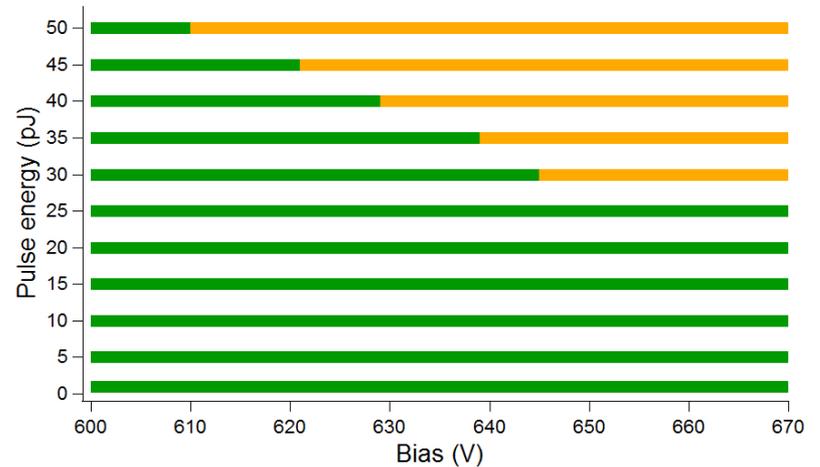
LGAD 2.5e15



PIN 1.5e15



PIN 2.5e15



■ Stable region
■ Unstable region
■ Damage region